IN THE CLAIMS

1-13. (cancelled)

- 14. (currently amended) A process for the production of an electrochromic coating on a substrate by <u>eathode</u> <u>chemical</u> sputtering of a target <u>consisting of tungsten or a tungsten alloy or containing at least one of Molybdenum, Titanium, Cerium, Vanadium and Zirconium, in a coating atmosphere containing a noble gas and hydrogen ions, wherein at least one gaseous hydrocarbon is added to the coating atmosphere in order to reduce the blind charge of the electrochromic coating.</u>
 - 15. (previously added) A process according to claim 14, wherein said noble gas is argon.
- 16. (previously added) A process according to claim 14, wherein said at least one gaseous hydrocarbon is a saturated hydrocarbon.
- 17. (previously added) A process according to claim 16, wherein said saturated hydrocarbon is methane.
- 18. (previously added) A process according to claim 16, wherein said saturated hydrocarbon is selected from the group consisting of ethane, propane and butane.
- 19. (previously added) A process according to claim 14, wherein oxygen is additionally added to the coating atmosphere.
- 20. (previously added) A process according to claim 19, wherein the volumetric ratio of added hydrocarbon to added oxygen is in the range of 3:1 to 1:3.

- 21. (previously added) A process according to claim 19, wherein the volumetric ratio of added hydrocarbon to added oxygen is 1:1.
- 22. (previously added) A process according to claim 19, wherein the volumetric ratio of noble gas to oxygen is in the range of 3:1 to 1:3
 - 23. (previously added) A process according to claim 22, wherein said noble gas is argon.
- 24. (previously added) A process according to claim 22, wherein the volumetric ratio of noble gas to oxygen is 1:1.
- 25. (previously added) A process according to claim 14, wherein operation takes place at a total pressure of the coating atmosphere of 0.3×10^{-2} mbar to 10^{-1} mbar.
- 26. (previously added) A process according to claim 25, wherein operation takes place at a total pressure of the coating atmosphere of 1×10^{-2} mbar to 4×10^{-2} mbar.

27-28 (cancelled)

29. (previously added) A process according to claim 14, wherein the electrochromic coating is applied to a thickness in the range of 50 nm to 500 nm.